



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of:

Jong-Woon OH et al.

Group Art Unit: 1744

Serial No.: 09/851,089

Examiner: Laura C. COLE

Filed: 9 May 2001

CLEANING APPARATUS FOR
SEMICONDUCTOR WAFER

AMENDMENT

U.S. Patent and Trademark Office
 2011 South Clark Place
 Customer Window, Mail Stop **Fee Amendment**
 Crystal Plaza Two, Lobby, Room 1B03
 Arlington, VA 22202

Sir:

In response to the Office Action dated 20 May 2003, the period for response to which is hereby being extended by the accompanying Petition and Petition Fee to 20 September 2003, please amend the above-identified patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 5 of this paper.

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